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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
09/902,250	07/10/2001	Gerald T. Mearini	0937.0016	9551	
75	90 09/02/2005		EXAMINER		
D. Joseph Eng	lish, Esquire		FULLER,	ERIC B	
Duane Morris L 1667 K Street, N	LP	·	ART UNIT	PAPER NUMBER	
Suite 700	·		1762		
Washington, D	C 20006		DATE MAILED: 09/02/2005		

Please find below and/or attached an Office communication concerning this application or proceeding.

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		Application No.	Applicant(s)	_ <i>UU</i> -
Office Action Summary		09/902,250	MEARINI ET AL.	
		Examiner	Art Unit	
		Eric B. Fuller	1762	_
The MAILING Period for Reply	DATE of this communication app	ears on the cover sheet with the c	orrespondence address	
THE MAILING DAT  - Extensions of time may be after SIX (6) MONTHS from the period for reply specture. If NO period for reply is specture to reply within the Any reply received by the	ATUTORY PERIOD FOR REPLY E OF THIS COMMUNICATION. e available under the provisions of 37 CFR 1.13 m the mailing date of this communication. Sified above is less than thirty (30) days, a reply secified above, the maximum statutory period w set or extended period for reply will, by statute, Office later than three months after the mailing ment. See 37 CFR 1.704(b).	within the statutory minimum of thirty (30) day ill apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication D (35 U.S.C. § 133).	· .
Status				
2a)⊠ This action is 3)□ Since this app	o communication(s) filed on <u>10 Ju</u> FINAL. 2b)☐ This plication is in condition for allowant ordance with the practice under E	action is non-final. ace except for formal matters, pro		
Disposition of Claims				
4a) Of the abo 5) ☐ Claim(s) <u>1</u> is/a 6) ☐ Claim(s) <u>2-4,6</u> 7) ☐ Claim(s) <u>5 and</u>	20 and 23-27 is/are pending in the claim(s) is/are withdraware allowed.  5,20 and 23-27 is/are rejected.  d 7-10 is/are objected to.  are subject to restriction and/or	vn from consideration.		
Application Papers				
10) The drawing(s  Applicant may a  Replacement d	on is objected to by the Examine ) filed on is/are: a) acce not request that any objection to the or rawing sheet(s) including the corrective	epted or b) objected to by the drawing(s) be held in abeyance. See on is required if the drawing(s) is ob	e 37 CFR 1.85(a). jected to. See 37 CFR 1.121(d	<b>I</b> ).
Priority under 35 U.S.0	C. § 119			
a) All b) S  1. Certified  2. Certified  3. Copies  application	ent is made of a claim for foreign ome * c) None of: d copies of the priority documents d copies of the priority documents of the certified copies of the priorition from the International Bureaued detailed Office action for a list of	s have been received. s have been received in Applicati ity documents have been receive ı (PCT Rule 17.2(a)).	on No ed in this National Stage	
Attachment(s)				
_	s Patent Drawing Review (PTO-948) Statement(s) (PTO-1449 or PTO/SB/08)	4)  Interview Summary Paper No(s)/Mail D  5)  Notice of Informal F  6)  Other:		

Application/Control Number: 09/902,250

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#### **DETAILED ACTION**

## Response to Arguments

Applicant alleges that Debley fails to teach evaporation and that the term "evaporator" as used in the claims is a general term that is used to refer to an electron beam gun and thus a "target", as taught by Debley, does not read on an "evaporator". This is not found convincing. Debley teaches a target that subjected to an ion gun releases some metal vapor. This reads on being an "evaporator". The term "evaporator" is a broad term that is open to multiple interpretations and it is unclear if the applicant is referring to a target that causes a vapor or the gun that provides the energy for the evaporation process, particularly in view of the evaporator being located in a source deposition location. Accordingly, the examiner has interpreted the claims to include either interpretation. If the term "evaporator" is amended such that it reads on the energy source for evaporation, this would overcome the rejections based on Debley. However, as the claims are currently drafted, the rejections of the previous Office Action are maintained.

Applicant argues that the "rearrangement of parts" is insufficient as a rejection as it would not be operable. This is not found convincing. Although the targets (fig 4, ref. 51' and 51") are moved form the standby location to the source deposition location by means of rotation, it still reads on being longitudinally spaced. To provide the apparatus such that the locations are laterally spaced would have been obvious with the expectation of achieving similar results. Although the location of the ion beam may

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have to be altered such that the angle of incidence is maintained, this is a minor adjustment that would have been within the ordinary skill of one practicing in the art, through routine experimentation. Although the applicant argues the case law required, this is inconsequential as the examiner maintains the position that the difference between longitudinally spaced and laterally spaced would not be a patentable difference. Therefore, the rejections of the previous Office Action have been maintained.

### Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 2, 3, 6, 23, and 24-27 are rejected under 35 U.S.C. 103(a) as being unpatentable over Debley et al. (US 5,529,671).

Debley teaches providing multiple substrates (column 8, lines 1-2; figure 4, refs. 63 and 64), a fixed ion source (column 7, lines 60-65; figure 4, ref. 19), a selectively movable target (evaporator) that is positioned at a standby position and source deposition location (figure 4, ref. 51), and material is deposited on the substrates. The shutters are taught (figure 4, line 20). Multiple targets that are moved into the source deposition location are taught (column 8, lines 9-29; figure 4, refs. 51' and 51"). The reference teaches the standby location being longitudinally spaced from the source

deposition location. Thus fails to teach it being laterally spaced. However, arrangement of parts such that the location is laterally spaced as opposed to longitudinally spaced would have been obvious with a reasonable expectation of success, as the mode of operation is not changed.

Claims 4 and 20 are rejected under 35 U.S.C. 103(a) as being unpatentable over Debley et al. (US 5,529,671), as applied to claim 3 above, and further in view of Kelley et al. (US 4,101,925).

Debley teaches the limitations of claim 3, as shown above, but fails to explicitly teach rotating the substrate. However, Kelley teaches that the speed at which the substrate is rotated is significant in achieving thin uniform layers (column 3, lines 58-65). Speeds within the applicant's claims are taught. It would have been obvious at the time the invention was made to a person having ordinary skill in the art to rotate the substrates of Debley by the speeds taught by Kelley. By doing so, one would reap the benefits of achieving uniform films.

### Allowable Subject Matter

Claim 1 is allowed.

Claims 5 and 7-10 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

The following is a statement of reasons for the indication of allowable subject matter: The prior art fails to teach, or make obvious, the limitation of ceasing deposition of the layer prior to achieving target thickness, by shuttering the substrates, then independently unshuttering the substrates to resume deposition in order to achieve target thickness, in combination with the limitations from which they depend.

#### Conclusion

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Eric B Fuller whose telephone number is (571) 272-1420. The examiner can normally be reached on Mondays through Thursdays.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Tim Meeks, can be reached on (571) 272-1423. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

**EBF** 

TIMOTHY MEEKS
SUPERVISORY PATENT EXAMINER